

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	9	("205"/50,57,60,67,76.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (molten) near10 salt	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 10:11
S2	302	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (molten) near10 salt	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 11:04
S3	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (molten) near10 salt and (5\$resist near5 pattern\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:35
S4	31	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (molten) near10 salt and (pattern\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 10:17
S5	2	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (molten) near10 salt and (pattern\$3) and (lithium adj bromide libr) and (cesium adj bromide csbr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 10:25
S6	6	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (molten) near10 salt and (lithium adj bromide libr) and (cesium adj bromide csbr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 10:26
S7	14	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (molten) near10 salt and (lithium adj bromide libr) and (cesium adj bromide csbr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 11:01

S8	19	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (lithium adj bromide libr) and (cesium adj bromide csbr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 11:03
S9	179	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (lithium adj bromide libr) and (ti w cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 11:03
S10	40	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (lithium adj bromide libr) and (ti w cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 11:04
S11	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten) near10 salt and (5\$resist near5 pattern\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:35
S12	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 salt and (5\$resist near5 pattern\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:35
S13	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt) and (5\$resist near5 pattern\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:36
S14	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt) and (5\$resist near15 pattern\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:37
S15	0	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt) and (5\$resist near15 pattern\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:36

S16	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt) and (5\$resist and pattern\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:38
S17	3183	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:39
S18	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt) and 5\$resist	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:41
S19	0	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt) and 5\$resist	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:40
S20	0	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt composition) and 5\$resist	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:40
S21	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (lithium adj bromide libr) and (cesium adj bromide csbr) and 5\$resist	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:07
S22	2	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (lithium adj bromide libr) and (cesium adj bromide csbr) and (pattern\$3 5\$resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:42
S23	198	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (pattern\$3 5\$resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:27

S24	171	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (pattern\$3 5\$resist) and (ti titanium tungsten w chrom\$4 cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:45
S25	171	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (pattern\$3 near105\$resist) and (ti titanium tungsten w chrom\$4 cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:46
S26	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (pattern\$3 near10 5\$resist) and (ti titanium tungsten w chrom\$4 cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:45
S27	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (5\$resist) and (ti titanium tungsten w chrom\$4 cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:46
S28	0	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (5\$resist) and (ti titanium tungsten w chrom\$4 cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:48
S29	63	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (5\$resist pmma) and (ti titanium tungsten w chrom\$4 cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:49
S30	466	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (resist photoresist pmma) and (ti titanium tungsten w chrom\$4 cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:50

S31	37	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and ((alkali alkaline) near10 (halide)) and (resist photoresist pmma) and (ti titanium tungsten w chrom\$4 cr) and (lithium adj bromide libr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 16:51
S32	4	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) near10 (ti titanium tungsten w chrom\$4 cr) and ((alkali alkaline) near10 (halide)) and (resist photoresist pmma) and (lithium adj bromide libr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:20
S33	3	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (lithium adj bromide libr) and (cesium adj bromide csbr) and (resist photoresist pmma)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:08
S34	6	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (lithium adj bromide libr) and (molten fuse\$3) near10 (bath salt) and (resist photoresist pmma)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:11
S35	27	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (lithium adj bromide libr) and (molten fuse\$3) near10 (bath salt) and (resist photoresist pmma)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:13
S36	10	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (lithium adj bromide libr) and (molten fuse\$3) near10 (bath salt) and (photoresist pmma)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:15
S37	243	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt) and (photoresist pmma)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:15
S38	183	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt) and (photoresist pmma) and pattern\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:16

S39	106	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt) and (photoresist pmma) same pattern\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:16
S40	87	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten fuse\$3) near10 (bath salt) and (photoresist pmma) same pattern\$3 and (ti titanium tungsten w chrom\$4 cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:20
S41	81	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten) near10 (bath salt) and (photoresist pmma) same pattern\$3 and (ti titanium tungsten w chrom\$4 cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:20
S42	23	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (molten) near10 (bath salt) and (photoresist pmma) same pattern\$3 and (ti titanium tungsten w chrom\$4 cr) and lithium	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:25
S43	9	(electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) and (photoresist pmma) same pattern\$3 and (ti titanium tungsten w chrom\$4 cr) and lithium near5 halide	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:26
S44	1879	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroform\$3 electroplat\$5) with (ti titanium tungsten w chrom\$4 cr) and (pattern\$3 5\$resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:28
S45	806	("205"/\$.ccls. "204"/\$.ccls.) and (electroform\$3 electroplat\$5) with (ti titanium tungsten w chrom\$4 cr) and (pattern\$3 5\$resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:29
S46	86	("205"/\$.ccls. "204"/\$.ccls.) and (electroform\$3) with (ti titanium tungsten w chrom\$4 cr) and (pattern\$3 5\$resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:29

S47	10	("205"/\$.ccls. "204"/\$.ccls.) and (electroform\$3) with (ti titanium tungsten w chrom\$4 cr) and (pattern\$3 5\$resist) and lithium	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:30
S48	37	("205"/\$.ccls. "204"/\$.ccls.) and (electroform\$3) with (ti titanium tungsten w chrom\$4 cr) and (pattern\$3 5\$resist) and (mold die)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/17 09:45
S49	106	(electroform\$3) with (ti titanium tungsten w chrom\$4 cr) and (pattern\$3 5\$resist) and (mold die)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/16 17:43
S50	238	"205"/50,67-79.ccls. and (electrodeposit\$5 electroform\$3 electroplat\$5) and (pattern\$3 5\$resist) and (mold die)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/17 09:47
S51	97	"205"/50,67-79.ccls. and (electrodeposit\$5 electroform\$3 electroplat\$5) and (pattern\$3 5\$resist) and (die)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/17 09:50
S52	0	"205"/50,67-79.ccls. and (electrodeposit\$5 electroform\$3 electroplat\$5) and (pattern\$3 near5 5\$resist) and (die)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/17 09:50
S53	25	"205"/50,67-79.ccls. and (electrodeposit\$5 electroform\$3 electroplat\$5) and (pattern\$3 near5 \$5resist) and (die)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/17 09:55
S54	21	"205"/50,67-79.ccls. and (electrodeposit\$5 electroform\$3) and (pattern\$3 near5 \$5resist) and (die)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/17 09:58

S55	26	("205"/\$.ccls. "204"/\$.ccls.) and (electroform\$3) and (pattern\$3 near5 \$5resist) and (die)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/17 10:01
S56	51	("205"/\$.ccls. "204"/\$.ccls.) and (electroform\$3) and (pattern\$3 near5 \$5resist) and (pattern\$3 near10 plating)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/17 10:25
S57	14	("3247573" "3414487" "3798059" "4586976" "4604160" "4753694" "5063658" "5233157" "5354205" "5358604" "5470412" "5480503").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/11/17 10:22
S58	14	("3247573" "3414487" "3798059" "4586976" "4604160" "4753694" "5063658" "5233157" "5354205" "5358604" "5470412" "5480503").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/11/17 10:22
S59	44	("205"/\$.ccls. "204"/\$.ccls.) and (electroform\$3) and (pattern\$3 near10 \$5resist) and (pattern\$3 near10 plating) and (ti titanium tungsten w chrom\$4 cr)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/17 10:27